

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,911,399 B2
DATED : June 28, 2005
INVENTOR(S) : Wei Liu and David Mui

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 2.

Line 15, change "to leave" to -- gas mixture to etch --.
Line 39, change "integrate" to -- integrated --.

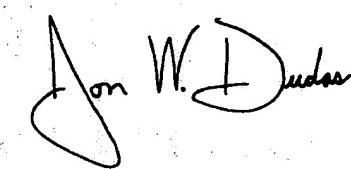
Column 8.

Line 7, change "claim 3" to -- claim 1 --.
Line 14, change "scorn" to -- sccm --.

This certificate supersedes Certificate of Correction issued April 11, 2006.

Signed and Sealed this

Second Day of May, 2006



JON W. DUDAS
Director of the United States Patent and Trademark Office